



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Re Patent Application of:

Yueh, et al.

Application No.: 10/750,042

Filed: 12/30/2003

For: A low outgassing and non-
crosslinking series of polymers for
EUV Negative Tone Photoresists

Examiner: Amanda C Walke

Art Unit: 1752

AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Office Action mailed August 8, 2005, which was made final, applicants respectfully request that the above-identified application be amended as set forth below. Applicants request continued examination of the application pursuant to 37 C.F.R. § 1.114.